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III-N Based Semiconductor Nanomaterials for Photonic and Electronic Devices

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Message from the Guest Editors

Dear Colleagues,

The aim of this Special Issue is to publish original research presenting very latest developments at the advancements in III-N based nanoscale device fabrication technology leading to the next generation Photonics and electronic devices for all kinds of applications. It is predicted that this will cover a wide range of ultraviolet to visible spectra region optoelectronic and electronic devices.

Prof. Joon Seop Kwak Guest Editor

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Message from the Editor-in-Chief

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